

IN THE U.S. PATENT AND TRADEMARK OFFICE

In re application of

Katsumi MAEDA et al.

Conf.

Application No. **NEW NATIONAL PHASE**

Group

Filed August 25, 2006

Examiner

STYRENE DERIVATIVE, STYRENE POLYMER, PHOTSENSITIVE RESIN
COMPOSITION, AND METHOD FOR FORMING PATTERN**INFORMATION DISCLOSURE STATEMENT
(SUBMISSION CONCURRENT WITH THE
FILING OF A NEW PATENT APPLICATION)**Assistant Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

August 25, 2006

Sir:

Pursuant to 37 C.F.R. §§ 1.97 and 1.98, and in fulfillment of the duty of disclosure under 37 C.F.R. § 1.56, applicant(s) hereby submit(s) an Information Disclosure Statement for consideration by the Examiner.

I. LIST OF PATENTS, PUBLICATIONS OR OTHER INFORMATION

The patents, publications, or other information submitted for consideration by the Office are listed on PTO-1449, attached hereto.

II. COPIES

- ☐ Copies of the U.S. patents or publications are not submitted since the USPTO has waived their submission for applications filed after June 30, 2003.
- ☐ Submitted herewith is a legible copy of (i) each foreign patent; (ii) each publication or that portion which caused it to be listed; and (iii) all other information or that portion which caused it to be listed.
- ☒ This application is a National Phase of a PCT application. Some or all of the documents listed on the PTO-1449 are not enclosed because they were cited in the International Search Report and copies should have been forwarded from the International Search Authority pursuant to the trilateral agreement between the USPTO, EPO and JPO, or they are U.S. patents or U.S. published applications. If copies are needed, please contact the undersigned.

III. CONCISE EXPLANATION OF THE RELEVANCE
(check at least one box)

a. ☐ **DOCUMENTS IN THE ENGLISH LANGUAGE**

The attached non U.S. patents, non U.S. patent application publications, foreign publications, or other information in the English language do not require a statement of relevancy.

b. ☐ **DOCUMENTS NOT IN THE ENGLISH LANGUAGE**

A concise explanation of the relevance of all patents, publications, or other information listed that is not in the English language is as follows:

c. ☒ **FOREIGN SEARCH REPORT OR ACTION**

An English language version of the search report or action that indicates the degree of relevance found by the foreign office is attached, thereby satisfying the requirement for a concise explanation. See MPEP 609(A)(3).

d. ☐ **OTHER**

The following additional information is provided for the Examiner's consideration.

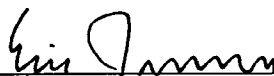
FEES

This Information Disclosure Statement is being filed concurrently with the filing of a new patent application; therefore, no fee is required.

If The Examiner has any questions concerning this IDS, he/she is requested to contact the undersigned.

Respectfully submitted,

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EJ/lbw

Enclosures: ☒ Form PTO-1449(s)
☒ Documents
☒ Foreign Search Report
☐ Other: _____

INFORMATION DISCLOSURE CITATION IN AN APPLICATION (Use several sheets if necessary)		Attorney Docket No.: 8017-1194		Application No.: 10/590804			
		Applicant: Katsumi MAEDA et al.					
		Filing Date: August 25, 2006		Group Art Unit:			
U.S. PATENT DOCUMENTS							
Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing date (if appropriate)	
FOREIGN PATENT DOCUMENTS							
Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation	
						Yes	No
	01-46862B	11/10/1989	JP				
	57-170929	10/21/1982	JP				
	2004-006273	1/8/2004	JP				
	61-005249	1/11/1986	JP				
	59-174604	10/3/1984	JP				
	62-276548	12/1/1987	JP				
	2001-356483	12/26/2001	JP				
	2002-296784	10/9/2002	JP				
	2003-114526	4/18/2003	JP				
	05-019473	1/29/1993	JP				
	56-27140	3/16/1981	JP				
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)							
	M. UEDA, et al. Journal of Photopolymer Science and Technology, Vol. 16(2), pp. 237 to 242 (2003)						
	K. EBARA, et al. Journal of Photopolymer Science and Technology, Vol. 16(2), pp. 287 to 292 (2003)						
EXAMINER: /John Chu/			DATE CONSIDERED 05/16/2008				
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.							

* English language abstract provided for the Examiner's convenience

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ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /JSC/